

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: Unknown

Inventor: Bor-Wen Chan

Serial No. To Be Assigned

Filed: Filed Herewith

For: Sidewall Polymer Deposition Method for Forming a
Patterned Microelectronic Layer

Attorney Docket No.: 67,200-1092

DISCLOSURE STATEMENT
UNDER 37 C.F.R. § 1.56

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In compliance with 37 C.F.R. § 1.56, the art listed and identified on the attached Form PTO-1449 is being submitted herewith for consideration by the Examiner.

It is Applicant's opinion that the claims presently on file patentably distinguish the present invention from each of these references. The above references are being cited only in the interests of candor and without any admission that they constitute

U.S.S.N.: To Be Assigned

statutory prior art or contain matter which anticipates the invention or which would render the same obvious, either singly or in combination, to a person of ordinary skill in the art.

Respectfully submitted,

TUNG & ASSOCIATES

By 

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FORM PTO-1449 (MODIFIED) LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	ATTY DOCKET NO.	SERIAL NO.
	67,200-1092	To Be Assigned
	APPLICANT Bor-Wen Chan	
	FILING DATE Filed Herewith	GROUP Unknown

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB CLASS	FILING DATE
	AA	5,453,156	9/1995	Cher et al			
	AB	6,110,837	8/2000	Linliu et al			
	AC	6,391,788	5/2002	Kahn et al			
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	COUNTRY	CLAS S	SUB CLASS	TRANSLATION YES/NO
	AK						
	AL						
	AM						
	AN						

OTHER ART (including Author, Title, Date, pertinent pages, etc.)

	AO	
	AP	

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.